



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

October 13, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG742504138

LABORATORY GROWN DIAMOND

EMERALD CUT

11.01 X 7.38 X 4.93 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

4.04 CARATS

D

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

EXCELLENT

EXCELLENT

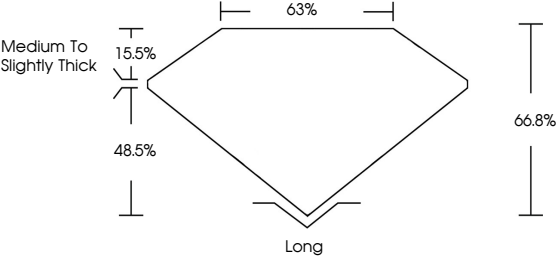
NONE

Inscription(s)

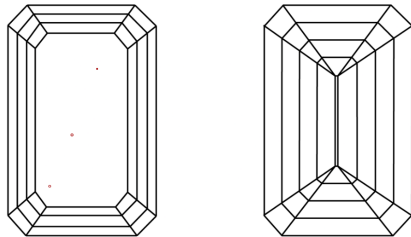
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG742504138

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

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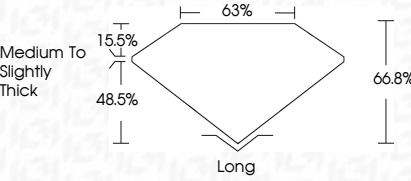
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PROPORTIONS



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EMERALD CUT

11.01 X 7.38 X 4.93 MM

Carat Weight

Color Grade

Clarity Grade

Table

Depth

Girdle

Medium to Slightly Thick

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

4.04 CARATS

D

VS 1

66.8%

48.5%

63%

66.8%

EXCELLENT

EXCELLENT

NONE

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